Panel Fan-Out Manufacturing Why, When, and How?



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Scaling or just another FO Packaging Technology?

1) Panel Fan-Out Manufacturing is here for some time already for Embedded and Non-Embedded Packaging Technologies, Chip-First and Chip-Last



2) The hot topic is: <u>Scaling of successful FOWLP Technologies</u> to larger manufacturing formats; FOWLP = Embedded Packaging Technology (EPT)



- EMBEDDING has Chip-First inherent in the technology;
- Interconnect Technology is Thin-Film RDL (no WB, no FC);
 - Substrate is Moldcompound, or Inorganic Materials (Si or Glass);
- Interconnect btw die pad and package I/O is formed on die + substrate.

Customer demand:

- Same results (1:1 copy) at lower cost enabled by larger format;
 - No additional FO technology, but transfer of construction & BOM.



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Wafer- and Panel-Level Manufacturing Environment





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The FOWLP Scaling Dilemma / WLFO Platform Approach



Scaling or just another FO Packaging Technology?

- Manufacturing Format Scaling is a <u>pure cost saving</u> topic w/o impact on:
 - Package Construction;
 - Design Features;
 - Bill of Material (BOM);
 - Reliability and Quality;
 - Test results and Yield levels.

FOWLP over FOPLP

- for project start phase
- for fast samples
- for small and medium volumes
- ➢ for complex WLSiP, WL3D products
- Changes to Package Construction and BOM result in modified Packaging Technology and cannot be considered as Manufacturing Format Scaling
- Economic Aspects have to be factored into the equation:
 - FOPLP has to be affordable for the industry (investment, volume, 2nd source, complexity, yield)
 - Deliver components to customer. Components packaged in **fully loaded high yielding** FOWLP line can be cheaper than components packaged in **half-loaded low yielding** FOPLP line !!!



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Dilemma 1:

FOWLP manufacturing format scaling to FOPLP has technical challenges; If solved by change in technology \rightarrow Another additional "Shade of Fan-Out".

Dilemma 2:

Volumes for FOWLP are coming from high density and Package Stacking solutions e.g. TSMC's InFO PoP \rightarrow Requires Semiconductor Environment = Wafer-Level.

Dilemma 3:

FOPLP manufacturing to utilize PCB, LCD or Build-up OSAT material, equipment, processes \rightarrow Cannot achieve the FOWLP design features and yield levels.

Dilemma 4:

FOWLP is increasingly used for more complex package constructions like WLSiP and WL3D with Passives and MEMS \rightarrow Complexity, high product mix, low volumes.

"Sweet Spot" for FOPLP will be in large package sizes, but with low complexity (Single Die, 1L-RDL) and needs stable large volumes to continuously load the line.



